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Surface-patterned chalcogenide glasses with high-aspect-ratio microstructures for long-wave infrared metalenses

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Multidimensional-engineering chalcogenide glasses is widely explored to construct various infrared photonic devices, with their surface as a key dimension for wavefront control. Here, we demonstrate direct patterning high-aspect-ratio microstructures on the surface of chalcogenide glasses offers an efficient and robust method to manipulate longwave infrared radiations. Despite chalcogenide glass being considered soft in terms of its mechanical properties, we successfully fabricate high-aspect-ratio micropillars with a height of 8 μ m using optimized deep etching process, and we demonstrate a 2-mm-diameter all-chalcogenide metalens with a numerical aperture of 0.45 on the surface of a 1.5-mm-thick As₂Se₃ glass. Leveraging the exceptional longwave infrared (LWIR) transparency and moderate refractive index of As₂Se₃ glass, the all-chalcogenide metalens produces a focal spot size of ~1.39 λ ₀ with a focusing efficiency of 47% at the wavelength of 9.78 μ m, while also exhibiting high-resolution imaging capabilities. Our work provides a promising route to realize easy-to-fabricate, mass-producible planar infrared optics for compact, light-weight LWIR imaging systems.

Keywords: chalcogenide glasses; long wave infrared; metalens

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Introduction

Chalcogenide glasses are a type of amorphous material composed of elements from the chalcogen group (sulfur, selenium, or tellurium), which hold significant importance in infrared optics due to their broad transparent window ranging from the near to longwave infrared wavelengths¹. Various engineering techniques have been developed to transform chalcogenide glasses into infrared optical components. For instance, these glasses can be drawn into optical fibers, offering promising applications in mid-infrared lasers² and supercontinuum generation³. Patterned chalcogenide films, produced

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through thermal evaporation and etching processes, have found applications in on-chip nonlinear optics for alloptical signal processing and sensors^{4,5}. Gradient-index chalcogenide glass, utilizing glass-composition-dependent refractive index^{6,7}, offers a novel approach for correcting chromatic aberrations in imaging systems8. Moreover, owing to their low glass transition temperature, chalcogenide glasses are well-suited for molding procedure, enabling cost-effective production of infrared lenses9. In addition to these bulk engineering methods, the surface of chalcogenide glasses also offers a crucial platform for engineering infrared optics, allowing for the creation of diffractive optical elements¹⁰ and microlenses11 using techniques such as precision glass molding or femtosecond laser processes. However, the aforementioned chalcogenide micro/nanostructures typically have an aspect ratio near 1 or lower. Considering that chalcogenide glasses are generally susceptible to brittle fracture, fabricating high-aspect-ratio microstructures on the chalcogenide glass surface remains a challenge.

Metasurface, consisting subwavelength artificial structures arranged in two-dimensional periodic array, offers an intriguing platform for full control of light wave¹²⁻¹⁵, which have been widely explored in quantum optics¹⁶, all-optical computing¹⁷, optical cryptography¹⁸, etc. As a typical metasurface specialized on phase manipulation, dielectric metalenses can focus light with the advantages of compact size, light weight, potential for integration with other optical components, which rely on high-asmicrostructures pect-ratio manipulate wavefront^{12,19-20}. Through meticulous design of both the individual microstructures and their spatial arrangement, diffraction-limited achromatic imaging performance could be achieved within a single piece of dielectric metalens. Typically, dielectric metalenses are fabricated using heterogeneous dielectric structures, i.e. high refractive index structures for phase manipulation and low refractive index substrate for mechanical support¹². Heterogeneous metalenses demonstrate impressive performance across shorter wavelength ranges, spanning from visible to mid-infrared frequencies^{21–26}. However, efficient phase control for longwave infrared light necessitates thick microstructure layers, often approaching the scale of the leveraging the exceptional longwave infrared (LWIR) wavelength (~10 μm). Fabricating such thick microstructures on a heterogeneous substrate poses significant challenges, including the potential for cracking or structural instabilities, arising from incompatible thermal expansion coefficients between different materials, which may deteriorate the mechanical stability of metalenses under varying ambient conditions. Direct patterning of metasurfaces onto transparent dielectric surfaces^{21,27,28} is a viable solution to address the challenges associated with heterogeneous metalenses in LWIR. Fan et al. demonstrate an all-silicon LWIR metalens efficiently focusing a CO₂ laser beam at 10.6 µm²⁹. Later works are dedicated to achieving large area³⁰ and large viewing angles³¹ in all silicon LWIR metalenses. Despite the well-established fabrication capabilities of the silicon platform, a noteworthy drawback of silicon stems from its inherent material loss-particularly significant absorption beyond 7 µm³². This characteristic stands as a limiting factor in the pursuit of high-efficiency all-silicon metalenses in the LWIR regime. Germanium is an appealing LWIR material due to its low absorption loss within the LWIR spectrum. Wang et al. utilize all germanium metalens for LWIR light focusing³³. However, the large refractive index of germanium introduces substantial reflection losses at the air-germanium interface, which requires an additional antireflection layer to mitigate this issue³⁴. Furthermore, the large temperature coefficient of refractive index (dn/dT) of germanium gives rise to pronounced focal shifts in response to changes in ambient temperature, potentially degrading imaging quality in practical applications.

In this paper, we demonstrate all-chalcogenide metalenses for LWIR imaging by directly patterning the surface of a chalcogenide glass. Employing an optimized deep etching process, chalcogenide micropillars with a height of 8 µm and varying diameters sitting on the same material are successfully prepared for efficient transmission wavefront control, despite chalcogenide glasses being soft in terms of their mechanical properties. Benefiting from the excellent LWIR transmittance of As₂Se₃ glasses, the fabricated all-chalcogenide metalenses demonstrate diffraction-limited focusing characteristics and high-resolution LWIR imaging performances. Compared to heterogeneous counterparts, the single-material (monolithic) LWIR metalens offer enhanced mechanical robustness and simplified fabrication processes. These advantages, including ease of fabrication and potential for mass production, position them as promising candidates for compact LWIR imaging devices.

Results and discussion

Properties of chalcogenide glass

We first show the advantages of chalcogenide glass

As₂Se₃ as the material for homogeneous LWIR metalenses. As₂Se₃ glasses demonstrate extremely low loss in the long-wave infrared band and low-temperature coefficient of refractive index (dn/dT), which have been widely explored in mid/long infrared applications ranging from optical fibers to thermal imaging lenses. Figure 1(a) shows a photo of a homemade and doublesided polished As₂Se₃ disk. We prepared As₂Se₃ glass disks with a diameter of 10 mm using single point diamond turning (SPDT) manufacturing technique (Nanoform X, Ametek Inc., USA) followed by a polishing process to ensure the high-parallelism and smoothness of the glass surfaces. Figure 1(b) shows the AFM images of the surface of as-prepared As₂Se₃ glass disks. The average surface roughness (Ra) and mean square roughness ($R_{\rm q}$) are 0.52 nm and 0.71 nm, respectively, indicating a surface smooth enough for subsequent processing. Figure 1(c) shows the measured transmittance of common LWIR materials. Here, CaF2, BaF2, ZnS, ZnSe, Si, and Ge substrates are double-side polished with a thickness of 1 mm, while the As₂Se₃ disk has a thickness of 1.5 mm. The transmittance spectra of different LWIR materials are measured by a Fourier transform infrared

(FTIR) spectrometer (Perkin-Elmer, Spectrum 100). The corresponding refractive index of these materials are summarized in Table 1. We could observe that substrate with a higher refractive index yields a lower average transmittance owing to larger Fresnel reflection, as depicted in Fig. 1(c), and the reflection losses would have a negative impact on the overall efficiency of metalenses. It should be noted that using antireflection coating on the structured surface may alleviate this34. However, it poses additional fabrication challenges. In addition, clear absorption peaks could be observed for the Si substrate, which is another key factor deteriorating the efficiency of all-silicon metalenses^{29,35}. As for fluoride materials (such as CaF2 and BaF2), the reflection loss could be suppressed, however, the low refractive index of these materials requires a large aspect-ratio microstructure to obtain entire 2π phase coverage. ZnS and ZnSe are popular LWIR materials with wideband infrared transparency and moderate refractive index, while currently these materials face difficulties for etching, especially for microstructures with micrometer-scale height applied in LWIR metalenses. Chalcogenide glass, including As₂Se₃, have excellent LWIR transparency. Figure 1(d) shows the

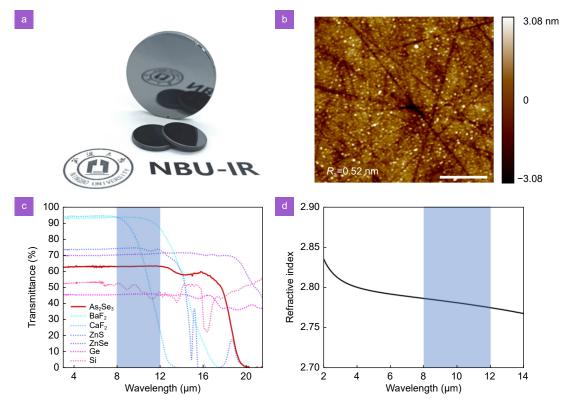


Fig. 1 | (a) Photo of double-side polished As_2Se_3 disks. (b) Two-dimensional AFM image of a polished As_2Se_3 disk, Scale bar: 1 µm. (c) Transmission spectra of common LWIR materials. The thickness of all samples is 1 mm, except for the As_2Se_3 , which has a thickness of 1.5 mm. The blue shaded region indicates the LWIR band ranging from 8 to 12 µm. (d) The refractive index of As_2Se_3 glass as a function of wavelength.

Materials	Refractive index	Transmittance ^(a)	d <i>n</i> /d <i>t</i>	Vickers hardness ^(b)	Expansion coefficient
	(at ~9.78 μm)	(at 9.78 µm)	(×10 ⁻⁶ K ⁻¹)	(HV)	(×10 ⁻⁶ K ⁻¹)
As ₂ Se ₃	2.78	63.2%	32	145	20.6
CaF ₂	1.3136	80.0%	-11.5 ³⁷	172	18.5 ³⁸
BaF ₂	1.4039	93.6%	-14.5 ³⁹	87	18.1 ³⁸
ZnS	2.2040	74.6%	46.341	167	17.2 ⁴²
ZnSe	2.4136	70.7%	52 ⁴¹	112	12.7 ⁴²
Si	3.4240	51.2%	150 ⁴³	~1050	2.64 ⁴⁴
Ge	4.0040	46.0%	40043	~800	5.945

Table 1 | Properties of As₂Se₃ glass compared with other long-wave infrared materials.

- (a) Data measured by FTIR spectrometer.
- (b) Data measured by Vickers hardness tester.

refractive index of As₂Se₃ glass in the infrared frequencies, obtained through an infrared ellipsometer (J. A. Woollam IR-VASE Mark II). In the LWIR region, As₂Se₃ glass demonstrate a moderate refractive index, e.g. 2.78 @ 9.78 μm, and the material dispersion is low as well, as denoted by the blue shaded area in Fig. 1(d). Moreover, its refractive index temperature coefficient is significantly lower than that of Si and Ge, resulting in good thermal stability under large temperature changes. Furthermore, although the thermal expansion coefficient of As₂Se₃ is higher than that of Si and Ge, it is comparable to other LWIR materials and is still in a small degree, which indicates that the structure expansion will not be large at high temperatures. These properties highlight As₂Se₃ glass as an ideal base medium for the preparation of homogeneous LWIR metalenses.

Chalcogenide glasses are usually regarded as being soft in terms of mechanical properties, compared with other materials. We measured the hardness of As₂Se₃ disk as well as other materials using Vickers hardness tester (MH-3, Hengyi Co., China), summarized in Table 1. It could be observed that the hardness of As₂Se₃ is much lower than Si and Ge, indicating a soft mechanical properties of chalcogenide glasses, and we will later show that high-aspect-ratio microstructures could be achieved on As₂Se₃ glass using an optimized fabrication process.

Design of all-chalcogenide glass LWIR metalens

Next, we present the design process of LWIR metalens based on all-chalcogenide glass microstructures. Here, we utilize the simple but effective local phase modulating unit cell: As_2Se_3 micropillars with varying diameters arranged in square lattices, which also features polarization insensitivity, as depicted in Fig. 2(a). The height and diameter of the micropillars are denoted as H and D, respectively, and the period is represented by P along both

the x and y directions, as shown in Fig. 2(b). Figure 2(c-d) show the transmittance and phase delay as functions of the height and diameter of micropillars with light incident from the substrate side. It can be observed that phase delay experiences large variation upon diameter changing and would have full 2π coverage when H is large enough. Diameter changing also results in transmittance fluctuations, which influences the overall focusing efficiency of metalenses.

To achieve a high transmittance as well as full 2π phase coverage, we choose $P = 5.5 \mu m$ and $H = 8 \mu m$. Figure 2(e) shows the corresponding transmittance and phase modulation curve as a function of diameter varying from 1.8 µm to 4.5 µm. We would like to emphasize here the average transmittance is mainly determined by the refractive index of the substrate. Therefore, compared with silicon- and germanium-based LWIR metalenses, a lower refractive index of As₂Se₃ helps to increase the average transmittance due to a lower reflection loss. Then, we select eight micropillars with different diameters as the metalens design units, i.e. the diameters are 2.00, 2.36, 2.58, 2.74, 2.93, 3.21, 3.59, and 4.12 μm, respectively, and micropillars with diameters from this library would introduce linear phase delay ranging from 0 to $7\pi/4$ with $\pi/4$ increment, as depicted in Fig. 2(f). The average transmittance of these 8 micropillars with different diameters is 74.8%.

When incident light impinges on the unit cell, each As_2Se_3 micropillar could be regarded as a truncated waveguide, where guided modes oscillate back and forth, forming a Fabry-Perot-like resonance. As depicted in Fig. 2(g), we plot three typical field profiles in one unit cell with different diameters, and the fields have different node numbers, indicating the different phase delay capabilities induced by the diameter modulation. Here, we consider the wavelength of the incident light to be

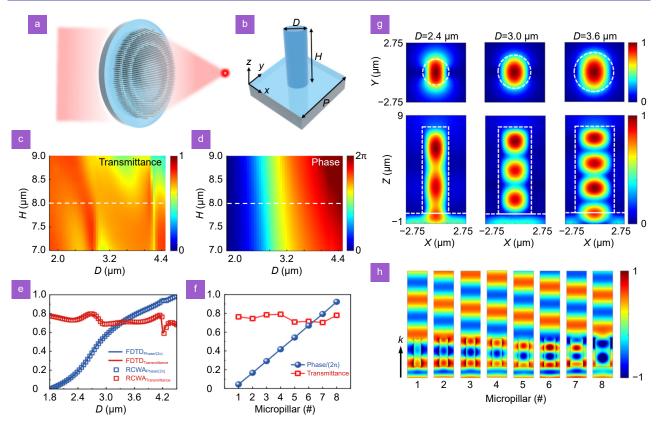


Fig. 2 | (a) Schematic for LWIR all-chalcogenide metalens operating in transmission mode. (b) Side view of the homogeneous metalens unit cell (As₂Se₃ micropillar on As₂Se₃ substrate with square lattice). (c, d) Transmission and phase diagrams as a function of the micropillar diameter *D* and height *H* at the wavelength of 9.78 μm, with a lattice constant *P* of 5.5 μm. (e) The transmission and phase of micropillar with different diameters were calculated at a lattice constant of $P = 5.5 \mu m$ and a height of $H = 8 \mu m$. (f) The transmittance and phase of eight selected micropillars, which can provide high transmittance and equidistant phase shifts covering the entire 2π range. (g) The normalized field profiles in As₂Se₃ micropillars with diameters (i) $D = 2.4 \mu m$, (ii) $D = 3.0 \mu m$, and (iii) $D = 3.6 \mu m$. The white dashed lines outline the micropillar structure and the electromagnetic field is tightly confined within the cylindrical structure. (h) The transmitted electric field in one unit cell with selected micropillar diameters, corresponding to 2(f).

9.78 µm, where the refractive index of As₂Se₃ is 2.78. The underlying physics is that the effective mode index n_{eff} is dependent on the diameter, and the phase delay can be obtained as $\varphi = k_0 n_{\text{eff}} H$, where the changing n_{eff} results in φ modulation⁴⁶. From this equation, we also know that the height of dielectric micropillar H would also influence the phase delay. Figure 2(h) shows the electromagnetic field from a unit cell with a micropillar from the design library. We observe that the transmitted light from micropillar with a larger diameter has a greater phase delay, confirming the phase manipulation capability of diameter-modulated micropillars. It should be noted that the electric field is mainly concentrated inside the micropillars, and the coupling between neighboring unit cells could be neglected, indicating each micropillar could locally tune the phase with the unit cell area.

The wavefront could be effectively controlled by arranging micropillars with different phase delaying capa-

bilities. Figure 3(a) shows a plane wave normally incident on an array of micropillars arranged from left to right with each having a phase delay ranging from 0 to $7\pi/4$ with a $\pi/4$ increment. In the region with z < 0 lies the As₂Se₃ substrate, and the region with z > 0 has As₂Se₃ micropillars embedded in air, emulating the actual working environment of metasurface. We could observe that the transmitted light deviates by approximately 13° from the normal direction, agreeing well with the theoretical deflection angle (12.84°) calculated from the generalized Snell's law²⁵.

Metalens transforms a plane wavefront into a converging one, where the required phase delay can be described as a hyperbolic function as

$$\varphi(x,y) = \frac{2\pi}{\lambda} (f - \sqrt{x^2 + y^2 + f^2}) ,$$
 (1)

where x and y are Cartesian coordinates with their origin located in the center of the metalens, φ is the phase

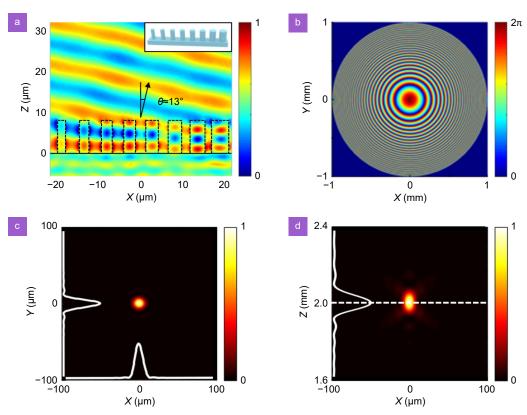


Fig. 3 | (a) Transmitted field profile through a beam deflecting metasurface with a deflection angle θ of 13°. (b) The discrete phase profile of an all-As₂Se₃ metalens with a diameter of 2 mm. (c) The intensity distribution of the light field on the *x-y* plane at the focal plane of the designed metalens. (d) Simulation of the normalized field intensity profile on the *x-z* plane at y = 0 µm after light passes through the metalens, concentrating incident light at the focal point with z = 2 mm.

delay at position (x, y), λ represents the working wavelength in free space, and f denotes the focal length. We aim to realize an all-chalcogenide LWIR metalens with an aperture diameter of 2 mm and focal length of 2 mm, corresponding to a numerical aperture (NA) of 0.45. In such a case, the chosen period is sufficiently small to meet the Nyquist sampling criterion, i.e. P < $\lambda/(2NA)^{46,47}$. Figure 3(b) shows the wrapped phase profile of the designed metalens. Owing to the rotational symmetry of the phase profile with respect to the metalens center, we could pick the parameter of the unit cell in the square lattice according to the distance to the center. We carried out a full wave simulation based on the finite difference time domain method to simulate the focusing properties of the designed metalens. Figure 3(c) shows the normalized electric field distribution (in the x-y plane) at the focal plane, and the FWHM of the focal spot is 11.9 µm, closing to the diffraction limit. Figure 3(d) shows the propagating focusing electric field along x-z plane at y = 0 µm. The incident light is tightly focused near z = 2 mm, confirming the validity of the design procedure.

Fabrication of the LWIR As₂Se₃ metalens

Figure 4(a) shows the schematics of the fabrication process of all-chalcogenide glass metalens. Initially, the homemade As₂Se₃ glass was cut, and polished, to ensure the parallelism of two sides. The As₂Se₃ glass disks have a diameter of 10 mm and a thickness of 1.5 mm.

The high-aspect-ratio As₂Se₃ micropillars require a deep etching process. On the prepared As₂Se₃ glass disks, we first spin-coat a photoresist film which is then baked and exposed by electron beam lithography (Raith eLINE Plus) to generate a negative metalens pattern. Subsequently, a chromium (Cr) layer with a thickness of 100 nm is deposited on the patterned photoresist film which was sequentially removed by an N-methyl-2-pyrrolidone (NMP) solution, leaving only the Cr pattern on the substrate. The As₂Se₃ glass disk with Cr hard mask is then etched with trifluoromethane and tetrafluoromethane (CHF₃ and CF₄) plasma until the etch depth reaches ~8 µm. For removing the residual Cr, we chose a hydrochloric acid solution, because common chromium removal solutions have strong oxidation properties, which would react with As₂Se₃ glass. For better Cr

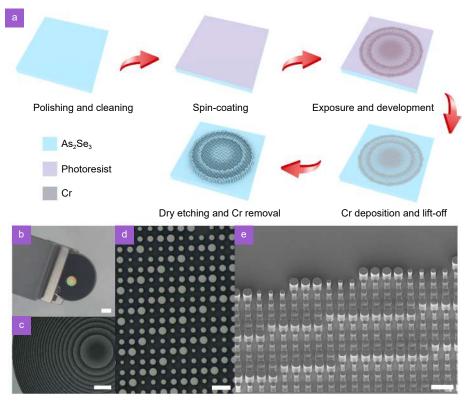


Fig. 4 | (a) Fabrication process of the all-chalcogenide glass metalens. The metalens is fabricated using a selective etching process. Initially, the photoresist is patterned using an electron beam exposure system. Following development, chromium (Cr) is deposited and the resist is removed. Subsequently, the As_2Se_3 glass undergoes dry etching with fluoride gas utilizing the Cr pattern as an etching mask. Cr exhibits low etching rates in fluoride plasma. Upon reaching an etched column height of 8 μm, the etching process is terminated, and the structure is immersed in a hydrochloric acid solution to dissolve the metal mask, leaving only the As_2Se_3 micropillar structure. (b) Photograph of the fabricated 2 mm diameter metalens on the surface of a As_2Se_3 glass disk with a diameter of 10 mm. Scale bar: 2 mm. (c) and (d) These images depict metalens captured under Olympus microscopes at different magnifications, with scale bars of 200 μm and 10 μm, respectively. (e) A zoomed-in view of the metalens captured by SEM. Scale bar: 10 μm.

removals, depositing a thin layer of aluminum before Cr could accelerate the hard mask removal speed. Figure 4(b) shows the photograph of an entire fabricated 10 mm-diameter chalcogenide glass disk with a 2-mm-diameter metalens structure on its surface. Microscope images (Olympus, BX51M) show the etched micropillars have a favorable morphology, as depicted in Fig. 4(c, d). Figure 4(e) presents a tilted scanning electron microscope (SEM) image of the fabricated metalens at the edge, showing a nearly vertical sidewall of micropillars. Note that owing to the soft and brittle mechanical properties of chalcogenide material, we need to optimize multiple etching parameters in order to achieve micropillars with vertical sidewalls and precisely controlled diameters (fabrication details are described in the Materials and Methods section).

Characterization of the LWIR As₂Se₃ metalens

To quantify the quality of the fabricated metalens, we

perform various characterizations including focal length, focusing efficiency, imaging resolution and temperaturedependent focusing performances. Figure 5(a) depicts the schematic of the measurement setup. A quantum cascaded laser (QCL, Ningbo Healthy Photon Co., Ltd, QC-Qube) emits a collimated beam at 9.78 µm LWIR light to illuminate the metalens from the substrate side. The transmitted light is collected by a reflective objective lens (ROL, Thorlabs, LMM-15XF-P01-160), and then directed into infrared focal plane arrays (FPA, IRay Technology Co., Ltd, M3640) for imaging the focal spot. The FPA has a resolution of 640×512 with a pixel size of 12 μ m \times 12 μ m. The FPA and ROL are sitting on a translational stage (Newport, M-462-XYZ-M). The measured intensity profiles at various distances (Δz) near the focal plane are depicted in Fig. 5(b), and the obtained focal length is 2 mm \pm 30 μ m, which agrees well with the design.

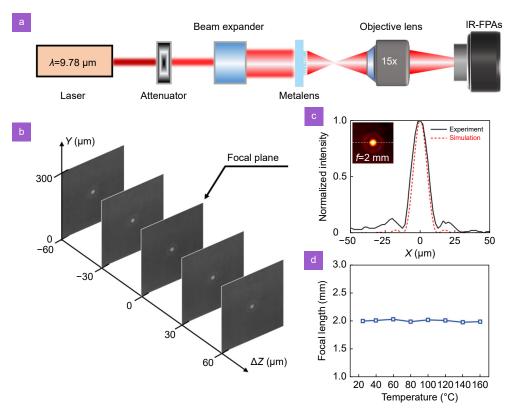


Fig. 5 | (a) The measurement setup utilized to characterize the focusing performance of the fabricated metalens. (b) Intensity profiles (x-y cross-section) measured at various distances (Δz) from the focal plane. (c) Cross-sectional views of the normalized light intensity profiles (represented by the black line) and calculated intensity profiles (represented by the red dotted line) along the x-axis direction on the focal plane. The inset is a focus image of the metalens. (d) Focal length of metalens at different temperatures.

Figure 5(c) shows the intensity distribution at the focal plane, and the inset shows the focal beam spot. To quantitatively assess the beam spot on the focal plane, the cross sections of the normalized experimental and simulated intensity profiles along the *x*-axis direction are plotted, as shown in Fig. 5(c). The simulation results indicate that the full-width at half-maximum (FWHM) of the focus is 11.9 μm, aligning closely with the theoretical diffraction limit formula $(0.514\lambda/NA)$, which approximates 11.2 μm. Note that the fabricated all-chalcogenide glass metalens with a diameter of 2 mm and a focal length of 2 mm, corresponding to a NA of ~0.45. The measured actual FWHM at the focal point slightly exceeds this at 13.6 μm.

LWIR camera may work in extreme environment, such as high ambient temperature. Common germanium-based LWIR lenses would have a degraded imaging performance due to increased optical loss induced by thermally generated holes when temperature rises above 100 °C. As₂Se₃ glass has a temperature coefficient of refractive index ($dn/dt = \sim 32 \times 10^{-6}/K$), nearly one order of magnitude lower than that of germanium, which promis-

es better thermal stability against large temperature variation. Figure 5(d) illustrates the focal length of the all-chalcogenide glass metalens under different ambient temperatures. With increasing temperature ($< T_g \approx 189$ °C) of the all-chalcogenide metalens, the focal length remains nearly constant, where small fluctuations may be caused by measurement inaccuracies.

Then, we characterize the focusing efficiency of fabricated metalens. The focusing efficiency is measured as the ratio of the light power passing through a pinhole with a 50 μ m diameter (Thorlabs, P50HK) around the focal point to the total light power incident on the 2-mm-diameter metalens area. We observe a periodic variation of transmitted light power (~50%) with respect to wavelength shifting of QCL induced by injecting current, due to the Fabry-Perot (F-P) interference occurring in the As₂Se₃ substrate. The F-P interference also leads to a sharp variation in transmitted light power with a slight change of the incident angle. In this case, it is difficult to determine the actual focusing efficiency. To mitigate this effect, we deposit an antireflection coating on the backside of the metalens, to suppress the reflection on the

smooth side of As_2Se_3 disk (See Supplementary information for detail). The measured focusing efficiency is 47% at a wavelength of 9.780 μ m, which is lower than the theoretical value of 58%. This discrepancy may be attributed to surface contamination, or manufacturing errors.

Figure 6(a) displays the USAF-1951 resolution test chart and its image captured by the as-fabricated allchalcogenide metalens, where the test chart is placed at a distance of 2f from the metalens. The smallest observable feature in the resolution test chart exhibits a line width of 31 µm, equivalent to 16.1 line pairs per millimeter (lp/mm). Figure 6(b) shows the high-temperature electric soldering iron imaged by the metalens without and with a narrow bandpass filter (Thorlabs, FB10000-500, 10 µm center wavelength, 0.5 µm FWHM). We could observe the broadband thermal emission from the soldering iron result in a blurry image on the edge, due to chromatic aberration, while the bandpass filter could improve the image quality with a sharper edge. Figure 6(c) and 6(d) shows the NBU logo on a polymer disk illuminated by a blackbody irradiation and a human hand imaged by the all-chalcogenide metalens.

Discussion

It is worth mentioning that despite their exceptional optical performance in the LWIR range, chalcogenide materials typically exhibit low mechanical strength and poor stability against humidity and environmental influences, which can negatively impact the long-term durability of all-chalcogenide metalenses. These drawbacks can be mitigated by using functional protective anti-reflection

coatings, such as diamond-like carbon films⁴⁸, which possess excellent mechanical properties and high corrosion resistance. These coatings can be further exploited to enhance the resilience of chalcogenide materials.

Table 2 summarize previously reported all-dielectric metalenses working in LWIR range. We observe that a heterogeneous Si/BaF2 metalens (ref.53) have a focusing efficiency of ~72%, attributed to reduced reflection loss resulted from low index BaF2 substrate (~1.4). In contrast, homogeneous metalenses based on silicon or germanium exhibit much lower focusing efficiencies, around 30%. Notably, the all-Si metalens reported in ref.⁵⁶ demonstrates a focusing efficiency of 64.94% with a low NA (0.1) design. Another trend observed is that all-Ge metalenses have a lower focusing efficiency of ~20.5% owing to a higher reflection loss. Compared with previous works summarized in Table 2, the all-chalcogenide (As₂Se₃) metalens shows improved focusing efficiency due to its excellent transmission and moderate refractive index (~2.78) within the LWIR range. Recently, we have noticed that ultra-flat lenses made from 2D materials offer an intriguing platform for efficient light field manipulation. Exploring LWIR imaging using atomically-thin 2D materials-based metalenses provides a novel avenue for further reducing the volume of infrared optical lenses49-52.

In our work, the measured focusing efficiency of allchalcogenide metalens is 47%. This value could be further improved by using antireflection coating on the structured side, which required a joint consideration of phase control and reflection reduction in the microstructure

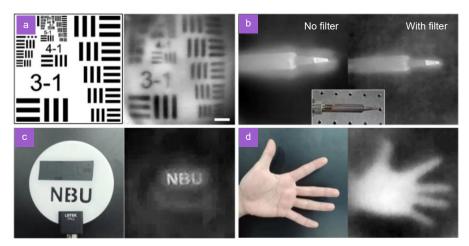


Fig. 6 | (a) The target resolution test chart (left), and the captured image of a resolution card (right) by all-chalcogenide metalens under blackbody radiation with a narrow bandpass filter. Scale bar: 200 μm. (b) The image of the high-temperature electric soldering iron captured by the metalens without (left) and with (right) the narrow bandpass filter. The inset is the photograph of soldering iron. (c) A polymer NBU logo and its image under blackbody irradiation with a narrowband filter. (d) The thermal image of a human hand captured by the all-chalcogenide metalens.

Ref.	Material	Aperture size	Wavelength	Focal spot size	N.A.	Efficiency
ref. ²⁹	Si	12 mm	10.6 μm	~1.08 <i>\lambda</i>	0.6	35%
ref. ⁵³	Si/BaF ₂	8 mm	10.6 μm	1.25λ/5.85λ	~0.45	72%
ref. ³⁵	Si	0.1 mm×0.1 mm	10.6 μm	~1.2 <i>λ</i>	~0.45	~34%
ref. ⁵⁴	Si	0.2 mm	8.5–11.5 μm	~1.68λ (@10 μm)	0.33	~10%
ref. ⁵⁵	Si	6 mm	10 µm	~0.89 <i>\lambda</i>	0.81	~24%
ref. ⁵⁶	Si	30 mm×30 mm	10.6/9.3 μm	~5.26 <i>λ</i>	~0.1	64.94%
ref. ⁵⁷	Ge	12.2 mm	8–12 μm	Not reported	~0.38	20.5% (@9.3 μm)
This work	As ₂ Se ₃	2 mm	9.78 µm	1.39λ	0.45	47%

Table 2 | Performance comparison of all-dielectric metalenses working in LWIR range.

design. We believe a multilayer microstructure metalens could help to achieve this goal^{58,59}. In addition, optimizing the diffraction efficiency at the peripheral region of high-NA metalenses offers a promising route to further improve the focusing efficiency^{60–63}.

Conclusions

In summary, we have established a new route to monolithically integrate metasurface on chalcogenide glass by directly pattern glass surface with high-aspect-ratio microstructures. With an optimized fabrication process, we successfully fabricate large-aspect-ratio micropillars with a height of 8 µm and varying diameters on the surface of As₂Se₃ glasses. The as-fabricated 2-mm-aperture allchalcogenide metalenses could efficiently focus LWIR light with a focal spot FWHM of $1.39\lambda_0$, closing to the diffraction limit. We also found homogenous metalens (i.e. microstructure and substrate made of the same materials) may be subject to strong transmission efficiency variation due to Fabry-Perot resonances in the substrate. By implementing an anti-reflection layer on the backside of the metalens, the measured focusing efficiency is 47%, while the theoretical value is 58%. Owing to the material properties of As₂Se₃ glasses, the fabricated metalens demonstrate good imaging performances, and stable focusing feature under varying ambient temperatures. Our work provides a new paradigm for realizing ultracompact, high-efficiency infrared optics using surface-patterned chalcogenide glass, which offers great potential for LWIR imaging systems applied in autonomous driving, airborne surveillance, personal night vision, and other weight-sensitive applications.

Materials and methods

Simulations: We perform numerical simulation to obtain the optical response of metalens unit cell using Lumerical FDTD solver. The refractive index of chalco-

genide glass (As_2Se_3) is 2.78, since As_2Se_3 has very low dispersion in LWIR frequencies. The square unit cell is embedded in air with a refractive index of 1. Periodic boundary conditions are imposed in the x-y plane. Plane wave source polarized along x-axis is injected to excite the unit cell. To obtain the transmittance and phase as a function of pillar height and unit cell period, we employ a MATLAB-based RCWA solver (Reticolo) to perform the calculation, and two methods show good consistency. The focusing performance of the all-chalcogenide metalens is simulated by Lumerical FDTD solver, and near-to-farfield transformation is utilized to obtain the focal spot field profile as well as focusing efficiency.

Fabrication: We pre-baked the chalcogenide glass disk at 150 °C for 10 min, then spin coated positive ebeam resists AR-P 6200.09 (Allresist) with a thickness of 200 nm and bake it under 150 °C hot plate for 8-min. Then spin coating 42 nm thick protective coating AR-PC 5090.02 (Allresist) for the dissipation of e-beam charges on insulating substrates and bake at 105 °C hot plate for 5-min. In all high temperature steps, there are 70 °C of hot plate insulation for 2 min after high temperature baking, in order to prevent glass substrate cracking. The 2 mm metalens pattern was written by 30 kV electron beam lithography (Raith eLINE Plus). After exposure, the conductive coating was removed by soaking in deionized water for 30 s, then developed with AR 600-546 developer (Allresist) for 1 min, fixed with IPA for 30 s, and baked on a 130 °C hot plate for 1 min. Then, the samples were brought into the sputtering chamber (Lesker, PVD 75) and a chromium (Cr) layer with a thickness of 100 nm is deposited on the patterned photoresist film which was sequentially removed by an Nmethyl-2-pyrrolidone (NMP) solution, leaving only the Cr pattern on the substrate. The As₂Se₃ glass disk with Cr hard mask is then etched by inductively coupled plasma (ICP, Oxford Instruments, PlasmaPro 100 Cobra

180) with trifluoromethane and tetrafluoromethane plasma (CHF₃:CF₄ = 20/10 sccm, 6 mTorr) until the etch depth reaches ~8 µm. For removing the residual Cr, we chose a hydrochloric acid solution, because common chromium removal solutions have strong oxidation properties, which would react with As₂Se₃ glass. For better Cr removals, depositing a thin layer of aluminum before Cr could accelerate the hard mask removal speed.

Measurement: The light at the focal spot is collected through a reflective objective (ROL, Thorlabs, LMM-15XF-P01-160) and then guided to an infrared focal plane array (FPA, IRay Technology Co., Ltd., M3640) to obtain a focal spot image. The FPA resolution is 640×512 and the pixel size is 12 $\mu m \times 12 \mu m$. FPA and ROL are fixed on a translational stage (Newport, M-462-XYZ-M). The light source is a quantum cascade laser (QCL, Ningbo Healthy Photon Co., Ltd, QC-Qube), which emits collimated LWIR light at 9.78 µm, and the spot size is expanded by a mid-IR Galilean beam expander (Thorlabs, GBE10-E3). The focusing efficiency is measured as the ratio of the light power passing through a pinhole with a 50 µm diameter (Thorlabs, P50HK) around the focal point to the total light power incident on the 2-mm-diameter metalens area. For the imaging tests, both the US-AF-1951 resolution test pattern and the NBU letter pattern are irradiated by a blackbody reference sources (CEM, BX-500), and the light passing through the pattern is then captured by the as-fabricated all-chalcogenide metalens after passing through a narrow bandpass filter (Thorlabs, FB10000-500, 10 µm center wavelength, 0.5 µm FWHM). The images produced by the metalens are collected through the reflective objective (ROL, Thorlabs, LMM-15XF-P01-160), and then guided to the uncooled thermal imaging module (IRay Technology Co., Ltd., M3S6) to obtain the final image.

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Author contributions

YX Gao, ZF Gu and X Shen developed the idea. ZF Gu and X Chen fabricat-

ed the devices. ZF Gu, YX Gao constructed the experimental setup, and characterized device performance. KS Zhou, JY Ge, and YX Gao conducted full-wave simulations to design the devices. ZF Gu, JY Ge, and YX Gao analyzed the data with contribution from YG Ma and L Xu. YX Gao, ZF Gu, L Xu, M Rahmani, R Jiang, YM Chen, ZJ Liu, CJ Gu, YG Ma, JR Qiu and X Shen discussed the results. YX Gao and ZF Gu wrote the manuscript with input from all authors. YX Gao and X Shen led the project.

Competing interests

The authors declare no competing financial interests.

Supplementary information

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